

# DAIMLER

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Urea to Ammonia Preparation for SCR-Systems in  
Commercial Vehicles – Fundamentals and Demands within  
the Product Development

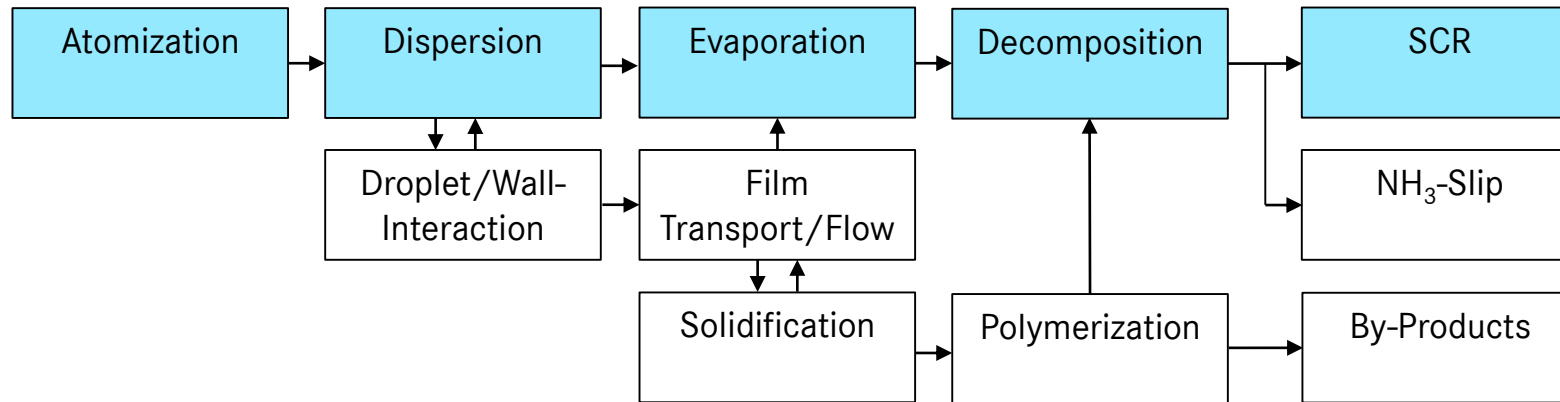
Ludwigsburg, February 20<sup>th</sup>, 2018

Daimler Trucks



# Governing Process Steps

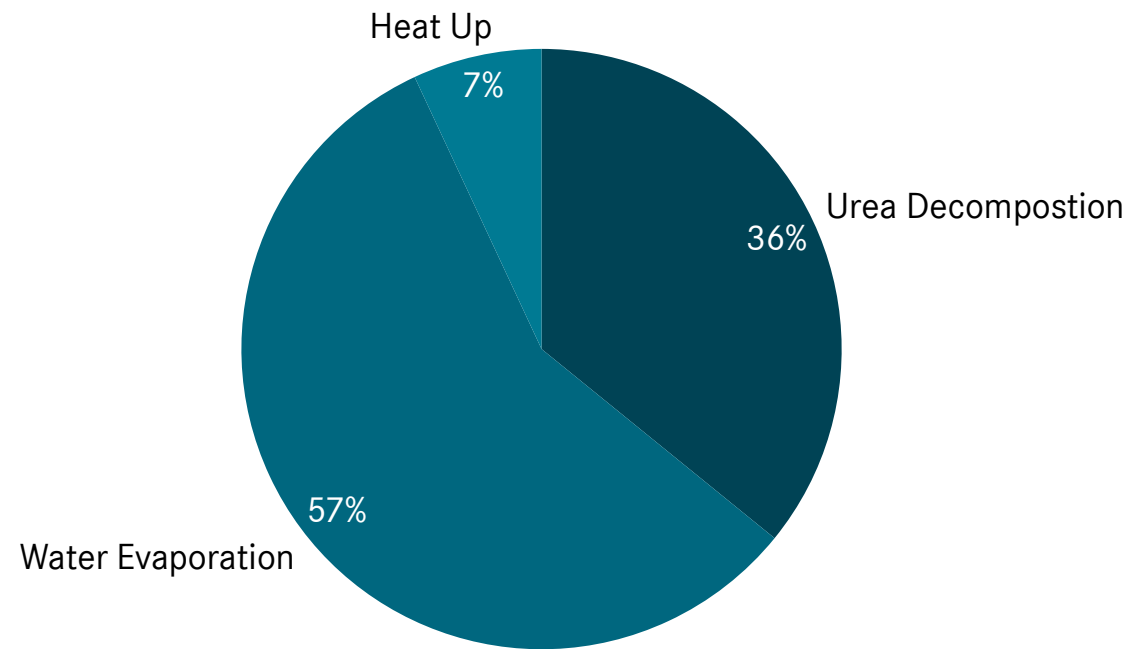
## Overview of Phenomena



■ Ideal path

- Ideally spray preparation w/o
  - wall contact / wall film
  - solid by-products
- In reality restrictions by
  - packaging
  - spray quality
  - low temperatures
- Aggregate trade-offs
  - backpressure
  - costs

# Required Energy for Preparation



Stagnant, 573K hot surrounding

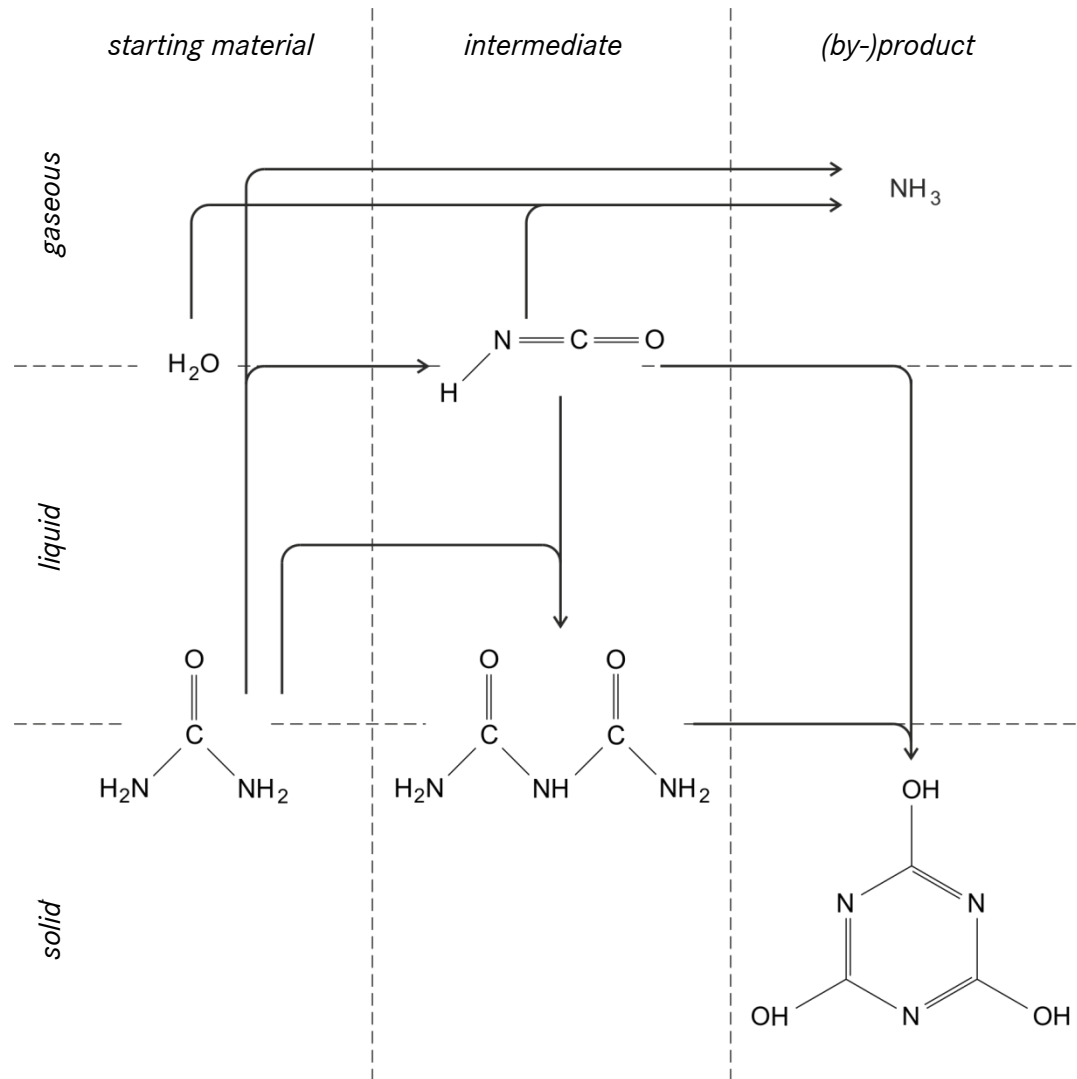
- Calculated for representative single droplet
- Starting conditions
  - 32.5% by weight
  - diameter of 70 $\mu$ m
  - temperature of 293K
- Decomposition consumes 1/3 of overall energy needed

# Available Deposit Assessments (Selection)

Authors	Key equation	Comment
Brack et al. (2014)	$\frac{dn_r}{dt} = A_0 \cdot e^{\frac{-E_A}{RT}} \cdot V_R \cdot \prod_j^i c_j^{y_j}, \quad r \in \{II, III, \dots, XIV\}$	Liquid phase reaction for each potential paths of urea towards by-products
Becker et al. (2014)	-	Empirical regime map of spray impingement surface load vs. wall temperatur
Ebrahimian (2012)	$r_k^{reaction} = \sum_{i=1}^{N_{reactions}} \nu_{ki} A_i' \exp\left(-\frac{E_{a,i}}{RT}\right) \prod_{j=1}^{N_{species}} C_{s_j}^{y_{ji}} \quad [\text{mol.cm}^{-2}.\text{s}]$	Solid phase reaction with active surface for each species; each potential reaction considered
Gan et al. (2016)	$\frac{\partial A_s}{\partial t} + \frac{\partial A_{su}}{\partial x} = \frac{S_m Y_u}{W \varepsilon},$	Active reaction surface for each species; each potential reaction considered; see Ebrahimian above
Schiller et al. (2015)	$EER = \frac{\dot{m}_{exhaust} * c_{p,air} * T_{exhaust}}{\dot{m}_{DEF} * c_{p,water} * (100 - 70) + \dot{m}_{DEF} * h_{fg,water}}$	Ratio of exhaust energy available and required energy for water evaporation
Smith et al. (2014)	-	Local deposit risk based on combination of injection rate, HNCO concentration, temperature etc.
Qian et al. (2017)	-	Only urea crystallization by phase diagram of uws considered
Zhang et al. (2017)	$F_D(T) = \sum_i y_i' F_i(T)$	Empirical correlation for urea decomposition
Zheng (2016)	$DFP = \alpha \frac{\text{film\_height}}{\max(\text{film\_height})} + (1 - \alpha) \frac{\max(\text{heat\_flux})}{\text{heat\_flux}}$	Appraisal index based on local film thickness, heat flux and weighting factor

- Numerous methods available
- Detail level and effort covered
  - from simple indices
  - to reaction kinetics
- Generally thermal conditions considered by all methods
- Topic is still work in progress indicated by ongoing activities

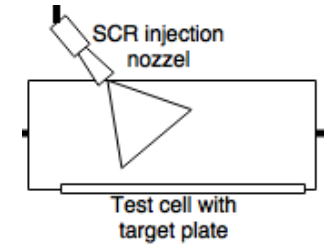
# Reaction Scheme w/ Aggregation States



- Urea converted to HNCO and Biuret as intermediates
- Cyanuric acid identified as main component in solid by-products
- Deposit build-up rate more pronounced in temperature span of 200...225 °C

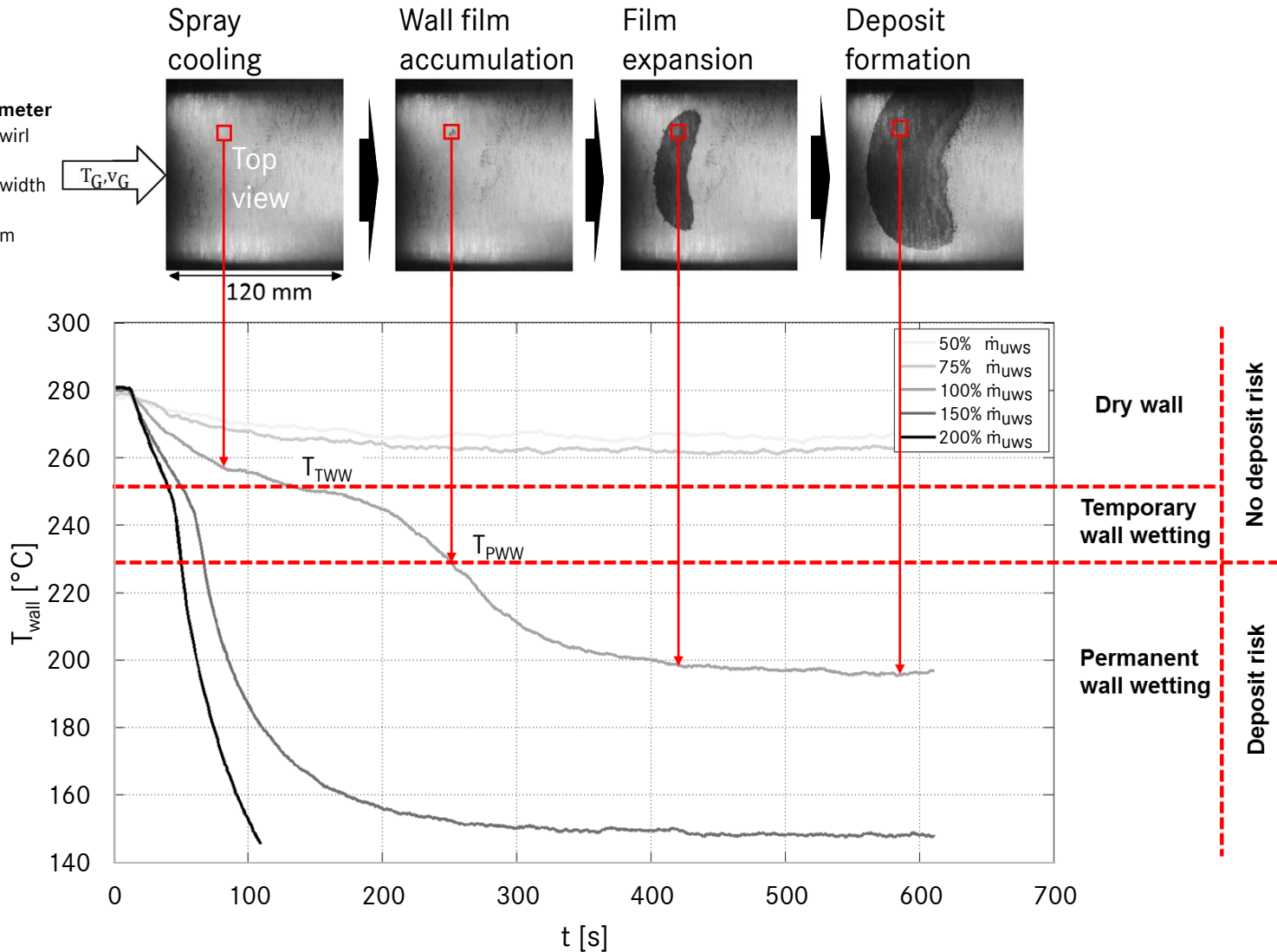
By-product reaction paths located in the vicinity of liquid interfaces / wall film.

# Analysis of Wall Wetting Regimes, Kettmann (2017)



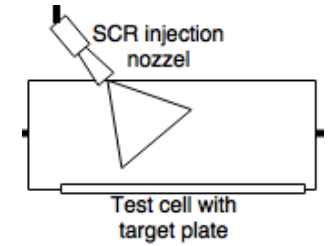
## Spray parameter

- Pressure-swirl atomizer
- 1Hz pulse-width modulation
- $D_{v90} = 95\mu\text{m}$

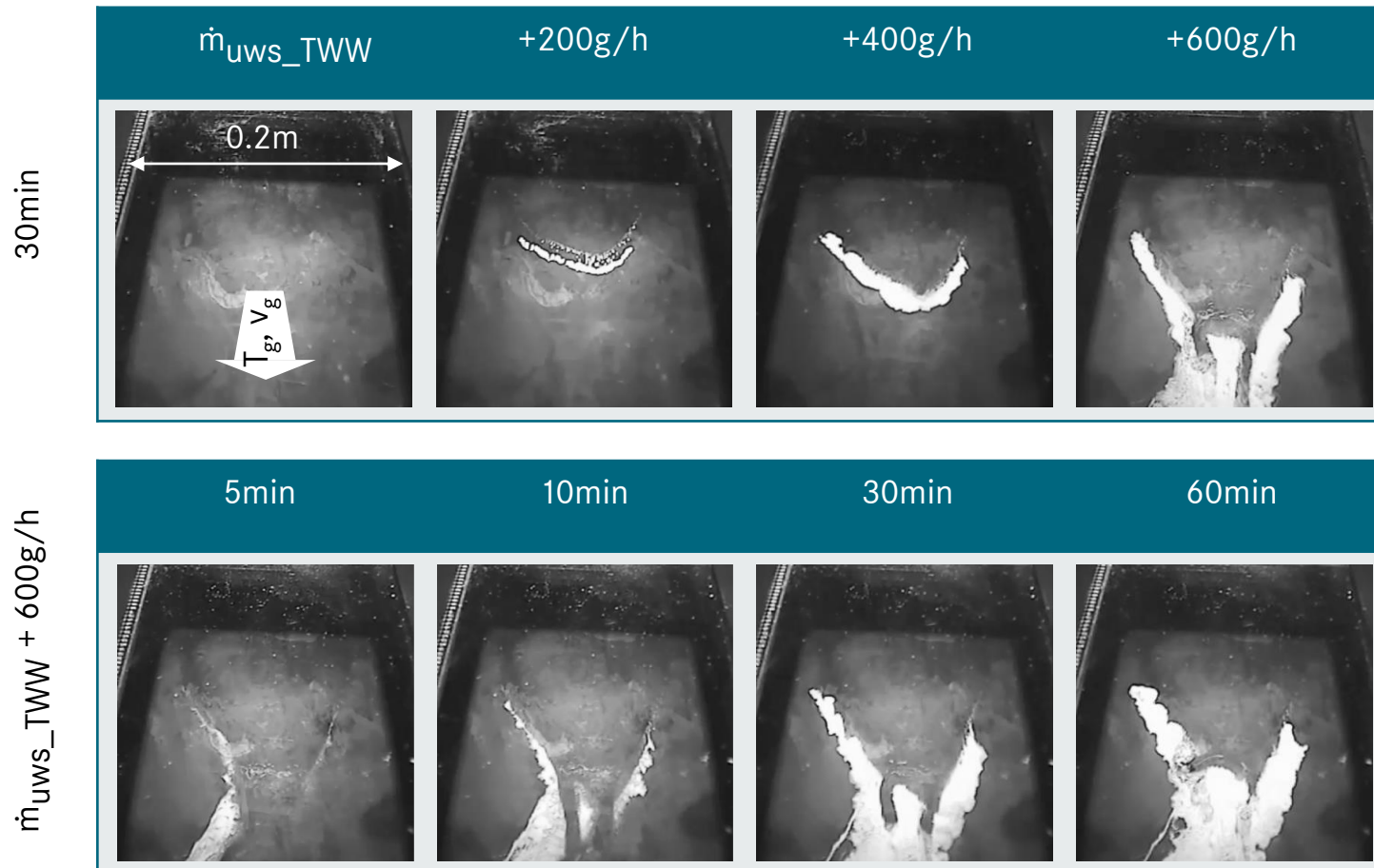


- Three regimes w/ pulsed spray
  - **Dry Wall**
    - No liquid deposition
  - **Temporary Wall Wetting**
    - Complete evaporation during one injection period
  - **Permanent Wall Wetting**
    - Accumulation of liquid
- Correlation of regime and wall temperature
- Deposit potential expected only in liquid wall film feed

# Deposit Growth Impingement Overload and Temporal Evolution



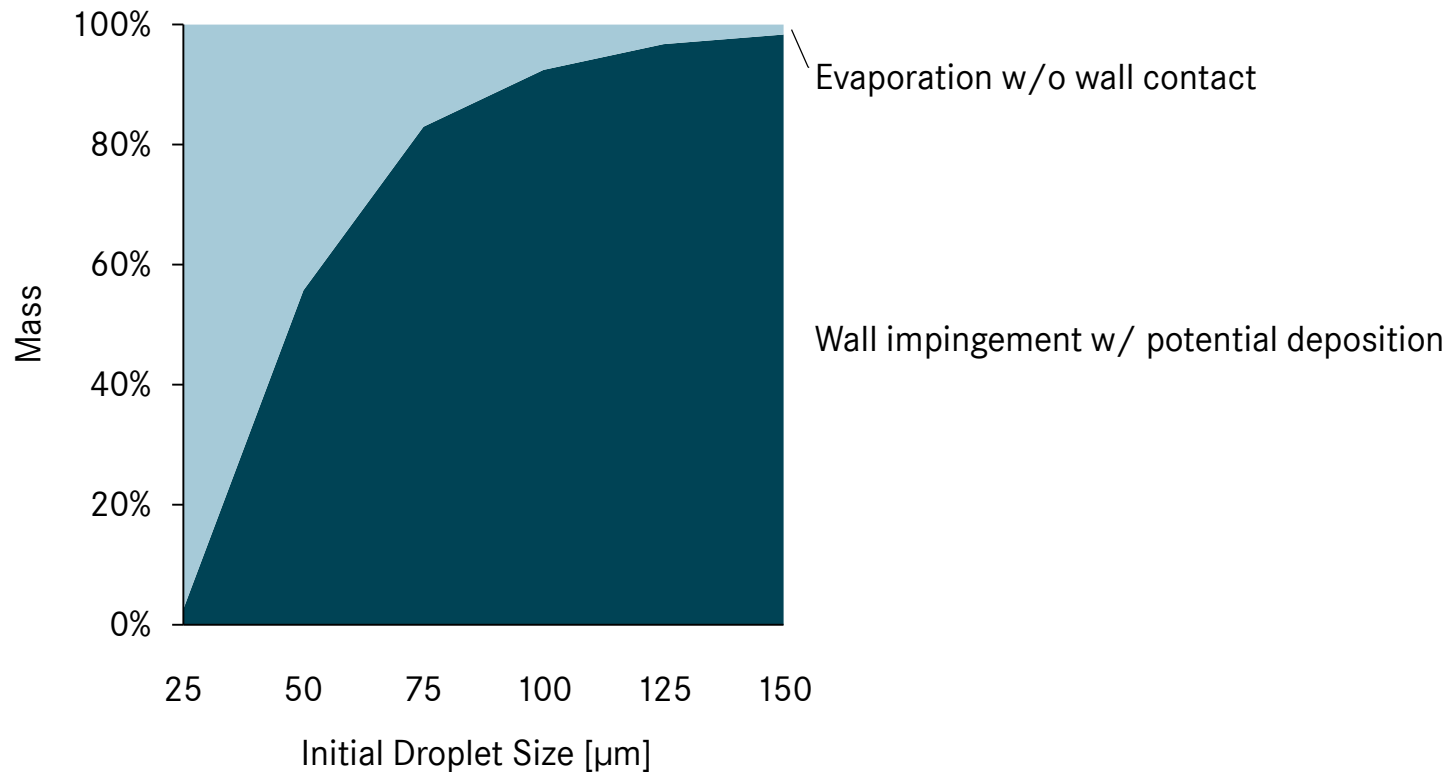
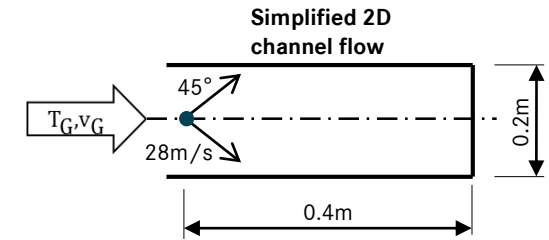
Angled top view, gas velocity 20m/s



- Deposit growth correlates to impingement overload
- For moderate overload deposit located near the wall film rim
- For strong overload streamlets break through
- Over time growth appears initially planar, then layered and shifted upstream

# Spray Evaporation

## Impact of Droplet Size on Wall Impingement

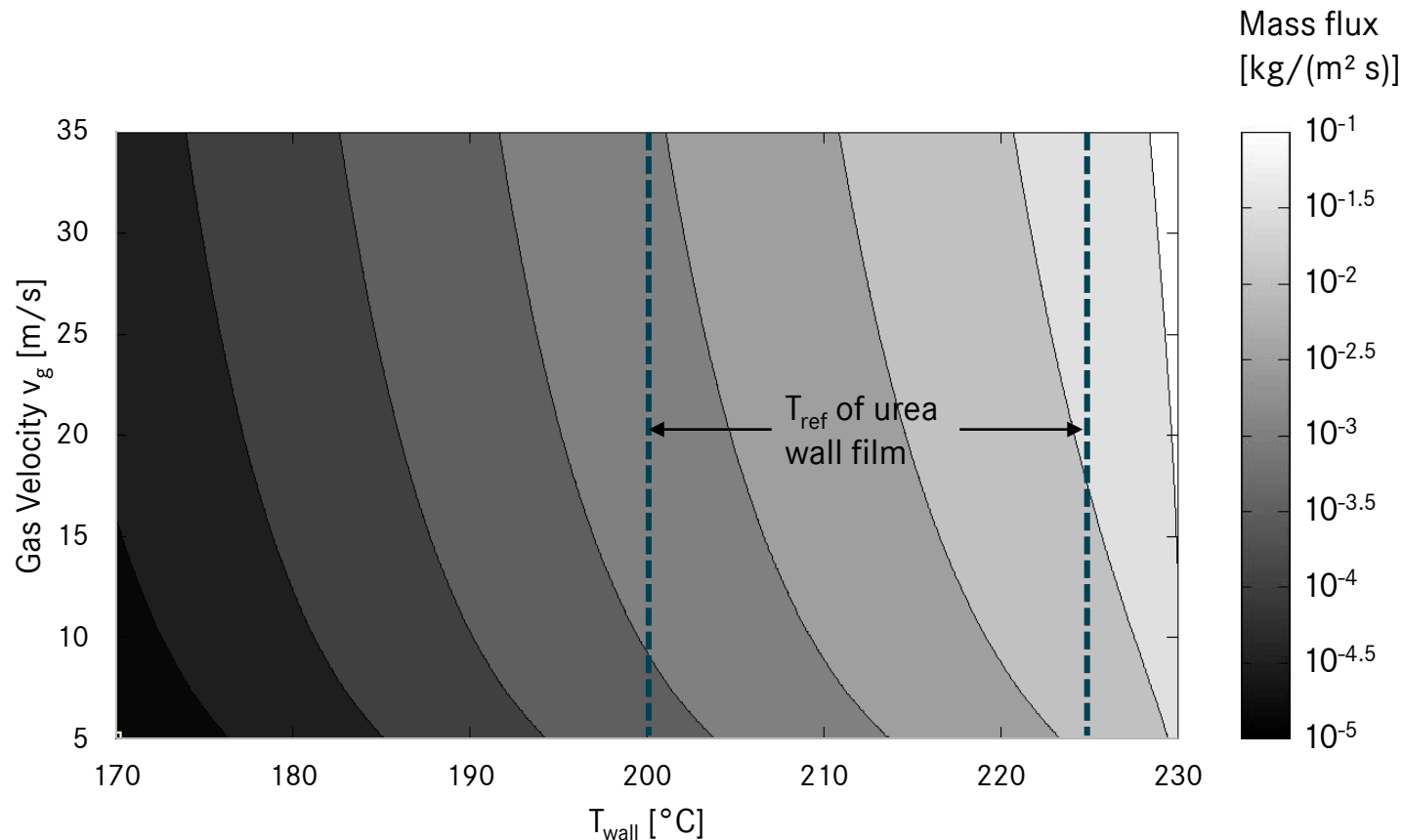


2D laminar flow 20m/s at 573K

- Mass hitting the wall calculated for single droplets
- Typically 30...80% impinged at wall in average
- Evaporation improved and deposit potential lowered w/ sizes below 50 $\mu\text{m}$  significantly
- Additional trade-offs determined by packaging and uniformity

# Wall Film Evaporation

## Mass Flux for Typical Boundaries



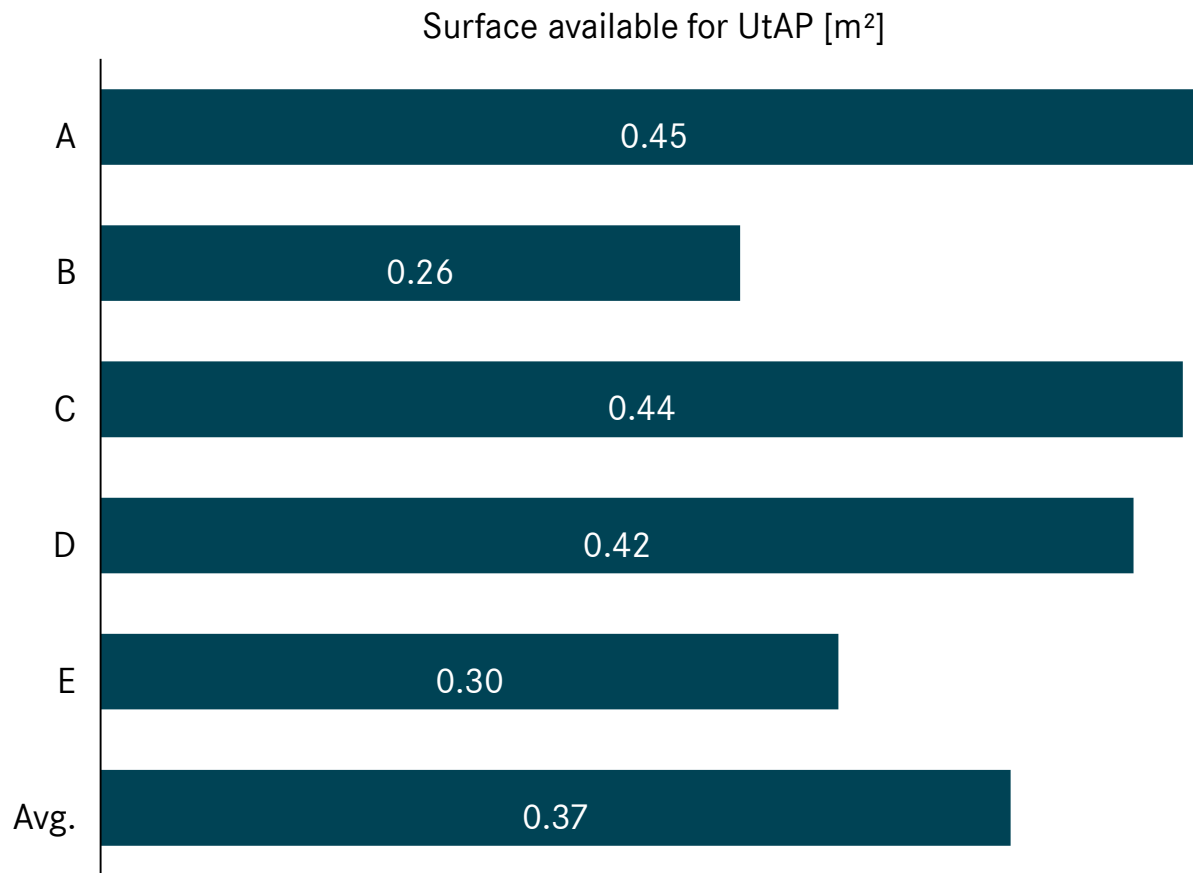
- Evaporation depends mainly on dynamic of urea vapor pressure
- Velocities determined by layout of mixing section and driving profile
- Wall temperatures and gas velocities correspond to typical boundaries in application
- Evaporation mass flux spanned from  $7 \cdot 10^{-4}$  to  $5 \cdot 10^{-2}$  kg/(m<sup>2</sup> s)

Calculation neglecting water content

$$\frac{\dot{m}_{\text{evap}}}{A} = \frac{\alpha}{c_{p,g} \cdot \text{Le}^{2/3}} \cdot \ln(1 + B_M) \quad \text{with} \quad B_M = f(p_{\text{sat},u})$$

# Current Heavy Duty Aftertreatment-Systems in Comparison

## Surface Area of the Mixing Section

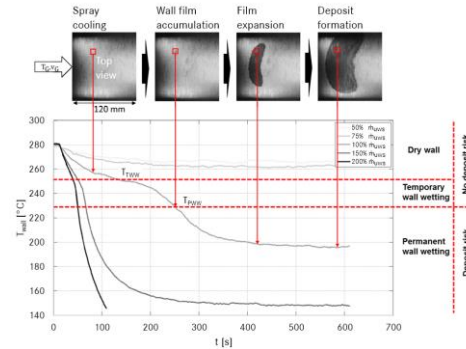


- Overall available surface for preparation estimated geometrically as indicator
- Mixing sections in today's aftertreatment applications equipped w/ surface around 0.37m<sup>2</sup> in average
- Trend for future applications expected to include increased surface up to 0.5m<sup>2</sup> in average

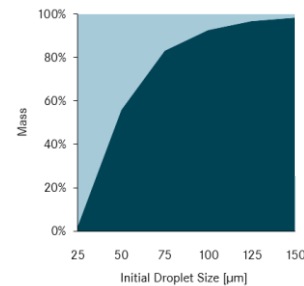
# Summary

- The system's capability for preparation is a product of

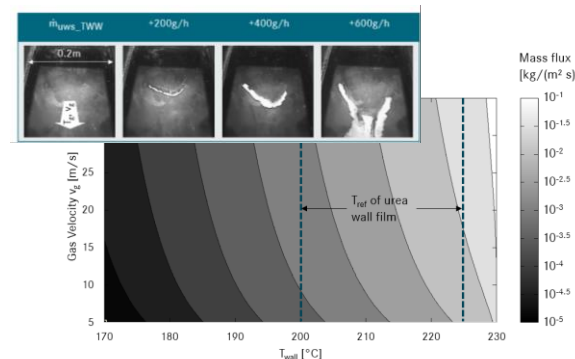
- thermal conditions due to exhaust gas temperatures / flow field,



- spray evaporation w/o wall contact due to droplet sizes and



- balances between wall film evaporation and impingement load / large surface area.



- Aggregate trade-offs between uniformity, backpressure and overall cost need to be fulfilled
- Injection rates corresponding to raw-NO<sub>x</sub> emission level expected to go up
- For better preparation the adjustments between the shown factors demanded

# Thank You for the Attention!



Source: Daimler | 2016\_07\_2584377\_2016\_07\_28\_Company\_charts.pptx

# Back Up

# Wall Film Evaporation

## Main Equations

$$\frac{\dot{m}_{\text{evap}}}{A} = \beta \cdot \rho_g \cdot \ln(1 + B_M)$$

$$p_{\text{sat,u}} = e^{-\frac{24238.62}{T} + 59.69}$$

$$\frac{\dot{m}_{\text{evap}}}{A} = \frac{\alpha}{c_{p,g} \cdot Le^{2/3}} \cdot \ln(1 + B_M)$$